## Synopsys Fusion Design Platform Extends Leadership at 7nm, Surpasses 100-Tapeout Milestone in First Year

Enables Lower Power, Higher Performance, and Faster Time-to-Market for 7nm Designs

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## **Highlights:**

- Fusion Design Platform customer deployment accelerates at 7nm driven by designers realizing 20% better QoR and more than 2X TTR speed-up on challenging designs
- Fusion Design Platform redefines conventional design tool boundaries with the fusion of best-in-class synthesis and place-and-route, and industry-golden signoff and next-generation design-for-test delivering the most predictable 7nm full-flow convergence with fewest iterations

Synopsys, Inc. (Nasdaq: SNPS) today announced that its Fusion Design Platform<sup>™</sup> has achieved a significant 7nanometer (nm) milestone surpassing 100 tapeouts in the first year, driven by customers realizing 20 percent better quality-of-results (QoR) and more than 2X time-to-results (TTR) speed-up. Comprised of Synopsys' market-leading digital design tools, the Fusion Design Platform redefines conventional tool boundaries, sharing engines and using a unique single-data-model for both logical and physical representation, and delivering lower power and higher performance on challenging 7nm designs.

"It is encouraging to see rapid deployment of the Fusion Design Platform by our customers," said Sassine Ghazi, co-general manager, Design Group at Synopsys. "We have worked closely with customer design teams to architect a platform that can tackle the escalating technical challenges at advanced process nodes. Using the Fusion Design Platform at 7nm, design teams can achieve new levels of productivity, increase their design differentiation, and get their end products to market much faster."

The Fusion Design Platform provides 7nm extreme-ultraviolet (EUV) single-exposure-based optimization, via pillars, and via stapling implementation for maximum design routability and utilization, and minimal IR-drop and electromigration. It provides the most predictable full-flow convergence at 7nm with the fewest iterations utilizing Design Compiler<sup>®</sup> Graphical and Design Compiler<sup>®</sup> NXT synthesis, IC Compiler<sup>™</sup> II place-and-route and Fusion Compiler<sup>™</sup> RTL-to-GDSII system, TestMAX<sup>™</sup> test and diagnosis, PrimeTime<sup>®</sup> signoff, StarRC<sup>®</sup> extraction, RedHawk Analysis Fusion power integrity, and IC Validator physical signoff tools.

Synopsys customers can learn more about 7nm design success by attending the Synopsys User Group (SNUG<sup>®</sup>) Silicon Valley on March 20-21, 2019 at the Santa Clara Convention Center in Santa Clara, CA.

## **About Synopsys**

Synopsys, Inc. (Nasdaq: SNPS) is the Silicon to Software<sup>™</sup> partner for innovative companies developing the electronic products and software applications we rely on every day. As the world's 15<sup>th</sup> largest software company, Synopsys has a long history of being a global leader in electronic design automation (EDA) and semiconductor IP and is also growing its leadership in software security and quality solutions. Whether you're a system-on-chip (SoC) designer creating advanced semiconductors, or a software developer writing applications that require the highest security and quality, Synopsys has the solutions needed to deliver innovative, high-quality, secure products. Learn more at www.synopsys.com.

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